## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

Naoki YAMAMOTO

Serial No.:

Not yet assigned

Divisional Application of Serial No. 09/639,306, Issued as

Patent No. 6,645,799

Filed:

Even date herewith

For:

METHOD OF MANUFACTURING A DUAL GATE SEMICONDUCTOR DEVICE WITH A POLY-METAL

**ELECTRODE** (As Amended)

Group:

2813 (expected)

Examiner:

Jack S. J. Chen (expected)

## **PRELIMINARY AMENDMENT**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 February 27, 2004

Sir:

Prior to initial examination on the merits, please amend t	he above-identified
application as follows:	

Amendments to the Specification begin on page 2 of this paper.

Remarks begin on page 5 of this paper.